



#### SCIENTECH

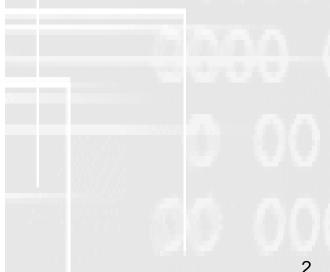
# (3583)

2020/6/24

## Safe Harbor Statement



- This Presentation contains certain forward-looking statements that are based on current expectations and are subject to known and unknown risks and uncertainties that could cause actual results to differ materially from those expressed or implied by such statements.
- Except as required by law, we undertake no obligation to update any forward –looking statements, whether as a result of new information, future events or otherwise.



# Scientech Corp (3583: TT)

Company Establishment	1979/10/17	
IPO	2013/3/12	
Capital	NT\$ 811 Million	
Chairman	H.L. Hsieh	
President	M.T. Hus	
Products	Equipment Manufacturing • Wa Trading(Agent/Distributor)	afer Reclaim



Business Overvies

#### **Products**

Future

Prospect

#### Business Overview

## **Income Statement**



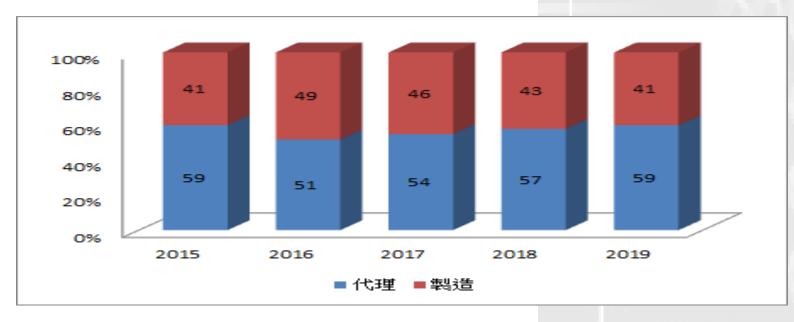
Units:NT \$ M	2015	2016	2017	2018	2019	1Q20
Revenues	2,942	3,495	3,539	3,988	3,949	630
Gross Profit	903	1,178	1,251	1,448	1,384	242
Operating Expenses	779	835	829	935	997	221
Operating Income	124	343	423	514	387	21
Other Income and Expenses	(6)	21	(8)	26	16	(16)
Income Before Tax	119	363	415	540	403	5
Net Income	86	292	328	418	323	3
EPS	1.06	3.60	4.05	5.16	4.02	0.03
Gross Margin	30.69%	33.71%	35.36%	36.32%	35.05%	38.47%
Operating Margin	4.23%	9.80%	11.95%	12.88%	9.81%	3.35%
Income Before Tax margin	4.03%	10.40%	11.72%	13.54%	10.22%	0.77%

#### Business Overview





Units : %	2015	2016	2017	2018	2019	Gross Margin
Trading	59	51	54	57	59	Below Average
Manufacturing	41	49	46	43	41	Above Average



#### Business Overview



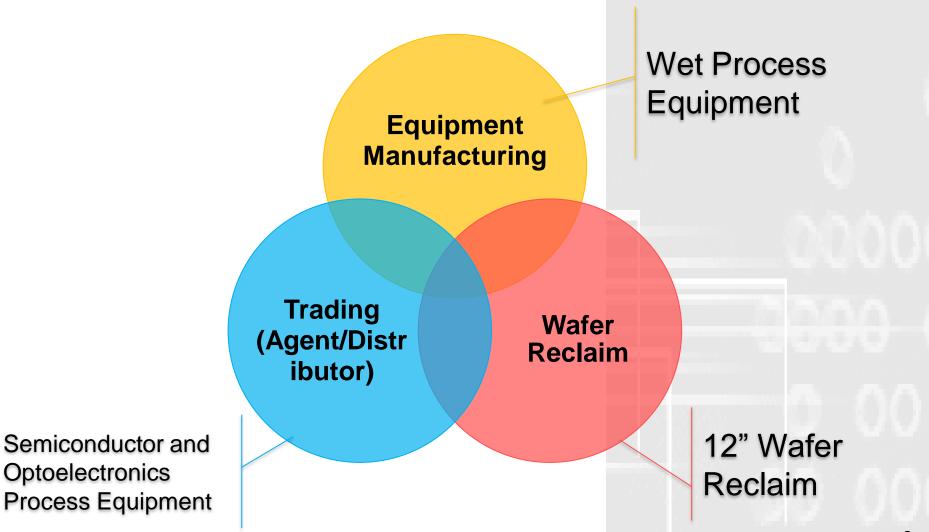


Units:NT\$M	2015	2016	2017	2018	2019
R&D Expenses	196	226	228	246	246
Expenses as % of Revenue	6.66%	6.48%	6.44%	6.18%	6.24%



#### Products





#### Products

### Equipment Manufacturing



#### Wet process equipment

- Single wafer/ Batch type
  - 8"/12' Advanced packaging

     (Fan-out < Solder Bump <</li>
     Copper Pillow < Bumping </li>
     Gold Bump < RDL < TSV</li>
     ...ect)

  - HB LED fully-automatic process
  - MEMS
  - ♦ III-V



#### Products

Line

# Si Wafer Reclaim



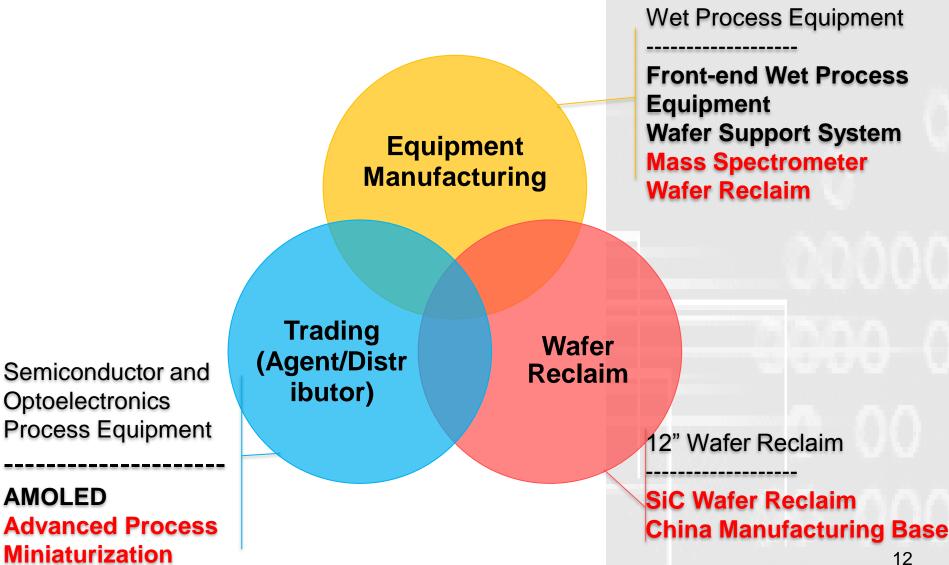
**Advanced clean technology Complete particle inspection 20nm/ 16nm Particle** (SP1-DLS & SP2) Low trace metal (<5E9) 12" Wafer Reclaim Etching Cleaning Capacity: 120K / month Separated Cu & Non Cu Full Process **Optimization** <mark>Grindin</mark>sj Rolishing **Complete polishing process Super flatness** Single side polish (GBIR<0.5µm) **Double, side polish Final Haze polish** 10



## Future Prospect

### **Product-based** Extension











### **Thank You!**